



OPEN

SUBJECT AREAS: SOLAR CELLS ELECTRONIC PROPERTIES AND MATERIALS

> Received 1 September 2014

Accepted 2 February 2015

Published 3 March 2015

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The electronic structure of metal oxide/ organo metal halide perovskite junctions in perovskite based solar cells

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Cross-sections of a hole-conductor-free CH₃NH₃PbI₃ perovskite solar cell were characterized with Kelvin probe force microscopy. A depletion region width of about 45 nm was determined from the measured potential profiles at the interface between CH₃NH₃PbI₃ and nanocrystalline TiO₂, whereas a negligible depletion was measured at the CH₃NH₃PbI₃/Al₂O₃ interface. A complete solar cell can be realized with the CH₃NH₃PbI₃ that functions both as light harvester and hole conductor in combination with a metal oxide. The band diagrams were estimated from the measured potential profile at the interfaces, and are critical findings for a better understanding and further improvement of perovskite based solar cells.

rgano lead halide perovskite is a promising material in photovoltaic solar cell research. During the past five years, the power conversion efficiency of perovskite based solar cells drastically increased, exceeding energy conversion efficiencies of $20.1\%^{1.2.5,8}$. A long diffusion length of electrons and holes was recently observed in organo metal halide perovskite and is one of the main reasons for the high solar cell efficiency^{3,4}. Several techniques are used for the perovskite deposition including solution-processed (one-step and two-step) deposition, evaporation method, and vapor assisted solution process (VASP)⁵⁻⁹. Solar cells with a high open circuit voltage of more than 1.3 V were demonstrated using CH₃NH₃PbBr₃ as the light harvester^{10,11}.

Despite the rapid increase in the photovoltaic performance of perovskite based solar cells, the operation mechanism of the metal oxide/perovskite junction is still under debate. In a recent work, the junctions of a $CH_3NH_3PbI_{3-x}Cl_x$ based solar cell were investigated by electron beam-induced current (EBIC) and a *p-i-n* junction was suggested 12. An indication for carrier accumulation in the perovskite absorber material was observed by impedance spectroscopy measurements 13. Kelvin probe force microscopy (KPFM), a scanning force microscopy based technique, was recently used to characterize the perovskite top layer 14,15 where the presence of a small potential barrier at the grain boundaries (GBs) was found. Bergmann *et al.* have recently measured cross-sections of a complete perovskite based solar cell under illumination with KPFM and showed that the potential is similar to a *p-i-n* type junction 16. KPFM is based on measuring and compensating the electrostatic forces between a sample and an AFM tip to obtain the contact potential difference (CPD) 17,18, which is a measure of the Fermi level energy if the electron affinity is known.

In this work, we use KPFM to measure the potential along the metal $oxide/CH_3NH_3PbI_3$ interface for two different nanocrystalline (nc) metal oxides, TiO_2 which functions as an electron acceptor due to the possibility for electron injection, and porous Al_2O_3 which acts as a scaffold¹⁹. In the current solar cell configuration the $CH_3NH_3PbI_3$ functions both as a light harvester and a hole conductor, therefore the solar cell operates without an additional hole transporting material. The chosen device structure facilitates the preparation of smooth cross-sections and simplifies the KPFM measurement and its interpretation. Our high-resolution KPFM measurements in the dark provide insight into the interface electronic structure. A surface space charge region of ca. 45 nm is determined for the nc- TiO_2 /Perovskite junction and is expected to enhance charge carrier separation and solar cell performance. The free carrier density was estimated from the band bending at the perovskite grain boundaries induced space charge region.

Results and Discussion

Kelvin probe force microscopy on cross-sections of hole-conductor-free perovskite based solar cell in dark (Fig. 1a) was used to determine the electronic structure of the interfaces that are critical for the performance

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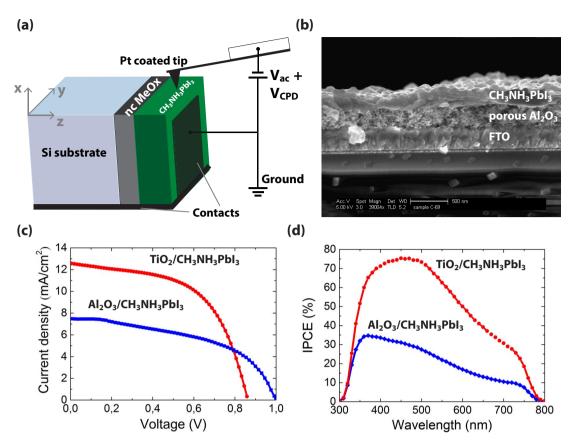


Figure 1 \mid (a) Schematic illustration of the KPFM measurement setup. The contact potential difference (CPD) is determined by compensating the electrostatic forces between the tip and sample where nc MeOx stands for nanocrystalline metal oxide. (b) HR-SEM images of the hole-conductor-free nc-Al₂O₃/MAPbI₃ perovskite solar cell.(c) Current-voltage curves of the studied solar cells and (d) the corresponding IPCE spectra.

of these solar cells. Perovskite solar cell cross-sections were prepared in a nitrogen glovebox by cleavage. Capillary forces were minimized allowing a small tip-surface distance hence better lateral resolution compared to an AFM setup in ambient. A typical structure of the hole-conductor-free perovskite solar cell is shown in the high resolution scanning electron microscopy (HR-SEM) micrograph (Fig. 1b). The MAPbI₃ perovskite is deposited on top of the metal oxide using the two-step deposition process described earlier^{6,20}. Table 1 and figure 1c show the photovoltaic parameters and the current voltage curves of the hole-conductor-free MAPbI3 $(CH_3NH_3 = MA)$ solar cells using nc-TiO₂ or nc-Al₂O₃ as the metal oxide. Figure 1d presents the incident photon to current efficiency (IPCE) of the corresponding cells. For both cells, the response covers the whole visible range. However, for the nc-TiO₂/MAPbI₃ cell, the IPCE reaches 75%, while for the nc-Al₂O₃/MAPbI₃ cell, 35% IPCE is achieved in good agreement with the current density-voltage (J-V) characteristics measured under a solar simulator. Upon visible-light excitation of the TiO2/MAPbI3/Au cell, electrons and holes are generated inside the perovskite layer. The electrons are then injected into the conduction band of the TiO2 and driven towards the FTO, whereas holes are transported through the perovskite layer to the Au contact.

For the $Al_2O_3/MAPbI_3/Au$ configuration, injection of electrons into the nanoporous Al_2O_3 is energetically not allowed; therefore,

the photogenerated charge carriers are transported through the $MAPbI_3$ film to the appropriate contacts.

The KPFM cross-section images of the two different cells in dark, nc-TiO₂/MAPbI₃ and the nc-Al₂O₃/MAPbI₃, are presented in Figure 2a and 2b. The high spatial resolution was achieved by maintaining the tip-sample distance below 5 nm at a slow scan rate of 0.1 Hz. The perovskite penetrates through the nc-Al₂O₃, sintered to the grounded contact; consequently, the Fermi level is assumed to be aligned and equal in all three layers. This allows a quantitative interpretation of the measured potential for both solar cell structures. Figure 2c and 2d show the CPD statistical distribution for the two interfaces; A CPD variation of 90 mV was determined for both metal oxides and a CPD variation of 65 mV was found for the perovskite layer. These variations are mainly due to the nanostructure and inhomogeneous surface of the measured materials entail a high amount of defect states. The measured average potential difference, Δ CPD, at the interface between nc-TiO2 and MAPbI3, as well as between the nc-Al2O3 and MAPbI₃ interface is 0.155 V and 0.12 V, respectively. Although the nc-TiO₂/MAPbI₃ based solar cell has a higher efficiency, the potential difference between the two interfaces in the dark (35 mV) is negligible small. Some of the perovskite grains have a lower CPD and are expected to be less active in the solar cell, as previously observed with EBIC measurements¹⁵.

Table 1 Photovoltaic parameters of the studied hole-conductor-free perovskite solar cells						
	Jsc (mA/cm²)	FF	Voc (V)	Efficiency (%)		
nc-TiO ₂ /MAPbl ₃ nc-Al ₂ O ₃ /MAPbl ₃	12.56 7.25	56 48.6	0.86 1.0	6.1 3.9		



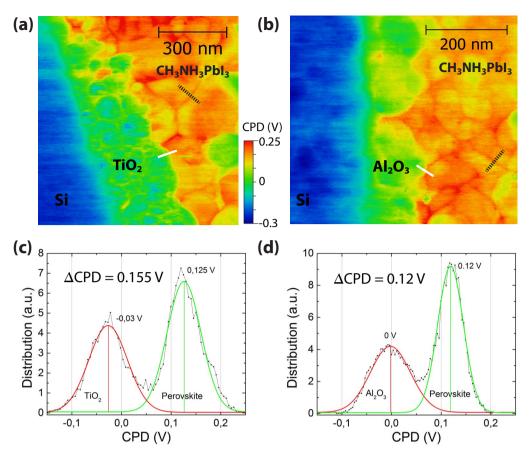


Figure 2 | KPFM images of solar cell cross-sections showing (a) the nc-TiO₂/MAPbI₃ and (b) the nc-Al₂O₃/MAPbI₃ interface. The white line indicates the CPD profiles shown in figure 4. (c) CPD statistical distribution for the CPD image of the nc-TiO₂/MAPbI₃ interface (d) CPD statistical distribution for the CPD image at the Al₂O₃/MAPbI₃ interface. The dashed line indicates the CPD profile along a grain boundary shown in figure 3b.

The CPD is higher (more positive) at the grain boundaries between adjacent perovskite crystals by ca. 25 mV (see figure 3b), implying a minor effect on the perovskite solar cell performance as this potential barrier is around the thermal voltage at room temperature. Figure 3a shows a schematic band diagram for the case of positive charge accumulation (hole traps) at the grain boundary. It is possible to calculate the width of the barrier potential at the grain boundaries using known barrier models^{21,22} provided the grain boundary is of negligible width compared to the grain size. This

model was used to analyze grain boundaries in p-type polycrystalline silicon, II-VI semiconductors and chalcopyrite materials.

The electrostatic screening length, L_S (within Ls charges are electrostatically screened; beyond this length charges are not affected by other charges) is extracted by fitting the measured potential profile across the GB (Fig. 3b) with an exponential function and is approximately 6.5 nm, which is much smaller than the average grain size of the perovskite (grains of around 200 nm can be observed in figures 2a and 2b). The dopant concentration, $N_{\rm d}$, can be estimated with equation 1^{22} ,

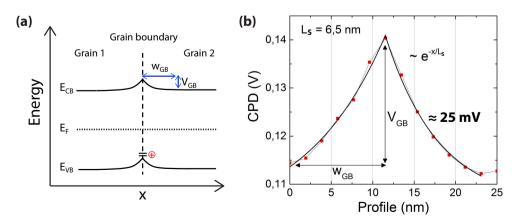


Figure 3 \mid (a) Electronic band structure at the grain boundaries where the potential is slightly higher (more p-type) compared with the grain body due to hole traps. V_{GB}-potential height at the grain boundaries. W_{GB}-width of potential barrier. (b) CPD profile along the grain boundary between two adjacent perovskite grains indicated in the CPD image of figure 2a.



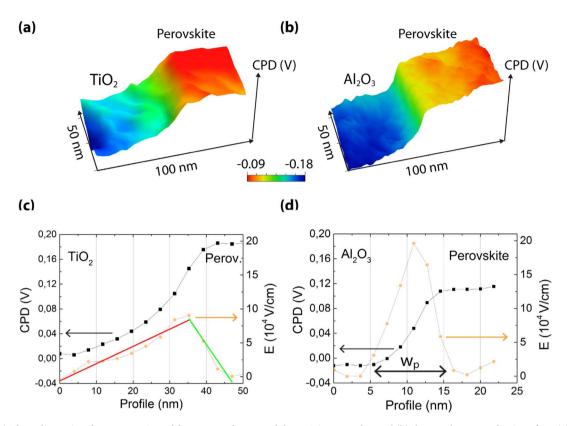


Figure 4 | (a) Three dimensional representation of the measured CPD and the nc-TiO₂/MAPbI₃ and (b) the nc-Al₂O₃/MAPbI₃ interface. (c) CPD profile and the corresponding electric field, dCPD/dx, for the nc-TiO₂/MAPbI₃ (d) for the nc-Al₂O₃/MAPbI₃ interface. The depletion width at the perovskite is defined as W_p .

$$L_{S} = \sqrt{\frac{\varepsilon k_{b} T}{q^{2} N_{d}}} \tag{1}$$

where $\epsilon=\epsilon_0\epsilon_p~(\epsilon_p\approx 20^{23}$ is the dielectric constant of the per-ovskite and ϵ_0 is the permittivity), k_b is the Boltzmann constant, T is the temperature and q is the elementary charge. By using extracted L_S in equation 1, the dopant density (N_d) was estimated to be $7\times 10^{17}~cm^{-3}$, which is in a good agreement with reported values observed by Guerrero $\it et~al.^{24}$

The CPD profiles of the metal oxide/MAPbI₃ interfaces, shown in figures 4a-d, provide estimation for the junction depletion width.

Figure 4c and 4d show the CPD and the electric field, E = dCPD/dx, across the interface for the nc-TiO₂/MAPbI₃ and the nc-Al₂O₃/MAPbI₃ cell structure, respectively. Accordingly, the depletion width for the nc-TiO₂/MAPbI₃ heterojunction is \approx 45 nm with a maximum electric field of $E \approx 9 \cdot 10^4$ V/cm. In the case of the nc-Al₂O₃/MAPbI₃ interface, there is no electron injection from the MAPbI₃ into the nc-Al₂O₃, since it functions rather as a scaffold. The electric field profile for the nc-Al₂O₃/MAPbI₃ interface is narrower, showing a depletion (space charge region) width of around $W_p \approx 10$ nm in the perovskite side of the junction (figure 4d). This corresponds to the depletion region width at the perovskite side at the nc-TiO₂/MAPbI₃ interface.

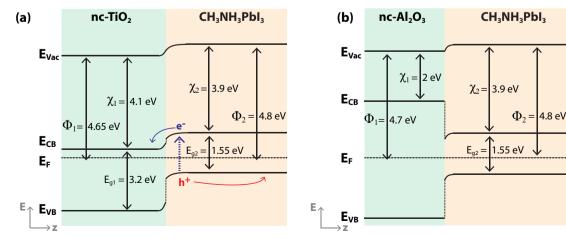


Figure 5 | (a) and (b) Band diagram of the TiO₂/MAPbI₃ and Al₂O₃/MAPbI₃ interfaces, respectively, calculated using the KPFM measurements. The conduction and valence bands position are according to Ref. 18 and 26.

 \mathbf{E}_{VB}



Table 2 Depletion region width, carrier density and maximum electric field at the junction							
Sample	Depletion width Wp/Wn (nm)	$N_{d\ (Perovskite)}$ (cm $^{-3}$) (calculated from the grain boundaries)	ΔCPD (V)	Electric field max. (V/m)			
nc-TiO ₂ /MAPbl ₃ nc-Al ₂ O ₃ /MAPbl ₃	10/35 Wp≈ 10	7 × 10 ¹⁷ 7 × 10 ¹⁶	0.155 0.12	9×10 ⁶			

Figures 5a and 5b show the suggested energy band diagrams for the nc-TiO₂/MAPbI₃ and the nc-Al₂O₃/MAPbI₃ interfaces using the measured work functions in dark. As opposed to the nc-Al₂O₃, the nc-TiO₂ has an active role in the electron transport. For the nc-TiO₂/MAPbI₃ interface (Fig. 5a) electron transport takes place mainly through the nc-TiO₂ since the electron injection is favorable. The measured space charge region at this interface assists in the charge separation and inhibits recombination which assist to the PV performance.

For the nc-Al $_2$ O $_3$ /MAPbI $_3$ interface, an oxide-semiconductor band structure is proposed with a relatively small band bending at the perovskite side. Since the 80 nm thin Al $_2$ O $_3$ layer is nanoporous, the perovskite penetrates through the Al $_2$ O $_3$ enabling electron transport to the contacts. We note that experiments with an Al $_2$ O $_3$ layer thickness >80 nm drastically reduced the solar cell performance.

The long diffusion length assists in the charges transport to the corresponding contacts.

Table 2 summarizes the parameters obtained in this study. The carrier density of the perovskite was calculated using the electronic barrier model; the depletion region width and the electric field were estimated from the cross section KPFM measurements.

Conclusions

Cross-sections of hole-conductor-free perovskite solar cells were measured using KPFM. The measured potential differences between the nanoporous metal oxide and the perovskite in dark are consistent for both nc-TiO₂ (Δ CPD = 0.155 V) and nc-Al₂O₃ (Δ CPD = 0.12 V) based cells and were used to estimate the band diagrams. Moreover, the measured width ($w_p = 10 \text{ nm}$) of the depletion region at the perovskite side is the same. However, while the measured band bending at the nc-Al₂O₃/MAPbI₃ side is negligible small, we measured a 45 nm depletion region width at the TiO2 side of the nc-TiO₂/MAPbI₃ interface. This depletion region contributes to the separation of photogenerated charge carriers and thus a higher performance of the TiO₂ based cells. The measured potential difference of 25 mV at the perovskite grain boundaries reveals hole accumulation at the GBs and plays a minor role for the solar cell performance. The results shed additional light on the electronic structure of these highly efficient perovskite based solar cells.

Experimental

Material synthesis. TiO₂ paste DSL 90-T composed of 20 nm particles was purchased from DYESOL. The TiO₂ paste was diluted with ethanol in ratio of 1:4 by weight and deposited by spin coating at 2000 r.p.m. for 10 sec. The TiO₂ film was annealed at 500° C for 30 min. The nc-Al₂O₃ 20 wt.% in isopropanol (<50 nm particle size) was purchased from Sigma-Aldrich. The nc-Al₂O₃ was diluted in isopropanol in ratio of 1:12 by weight. The deposition and the annealing conditions were the same as for TiO₂.

CH₃NH₃I was synthesized as described previously²⁵, by reacting 30 mL of methylamine (40% in methanol, TCI) and 32.3 mL of hydroiodic acid (57 wt% in water, Aldrich) in a 250 mL round bottom flask at 0°C for 2 h with stirring. The precipitate was recovered by putting the solution on a rotavap and carefully removing the solvents at 50°C. The yellowish raw product of methylammonium iodide (CH₃NH₃I) was washed with ethanol by stirring the mixture for 30 min. Then the mixture was filtered and washed three times with diethylether. After filtration, the solid was collected and dried at 70°C in a vacuum oven for 24 h.

Device fabrication. The substrate of the device was a SNO $_2$: F (FTO) conducting glass (15 Ω ·cm $^{-1}$), Pilkington). A blocking layer was deposited on the FTO glass using a solution of titanium diisopropoxidebis(acetylacetonate) (TiDIP, 75% in isopropanol, Aldrich) in ethanol. The TiDIP solution was spin coated and then annealed at 450°C for 35 min. The TiO $_2$ solution or the Al $_2$ O $_3$ solution were spin

coated and annealed at 500°C for 30 min subsequent to TiCl $_4$ treatment for 30 min at 70°C and annealing at 500°C for 30 min.

The synthesis of the CH₃NH₃PbI₃ on the TiO₂ surface was carried out by a twostep deposition technique.

First, PbI₂ was dissolved in DMF and dropped onto the TiO₂ film and spin coated, followed by annealing at 70° C for 30 min. In the second step, the cell was dipped into methylammonium solution. Following the dipping step, the samples were annealed at 70° C for another 30 min. Finally, the back contact was deposited by evaporating 50 nm of gold under pressure of $5*10^{-6}$ Torr. The active area was 0.09 cm².

The KPFM cross sections samples were prepared on a crystalline silicon substrate. The Si wafer was etched from native oxide by hydrofluoric acid (48 wt% in water, Aldrich) for 15 min and cleaned by oxygen plasma for 1 min.

Photovoltaic characterization. Photovoltaic measurements were made on a New Port system, composed of an Oriel I-V test station using an Oriel Sol3A simulator. The solar simulator is class AAA for spectral performance, uniformity of irradiance, and temporal stability. The solar simulator is equipped with a 450 W xenon lamp. The output power is adjusted to match AM1.5 global sunlight (100 mWcm⁻²). The spectral match classifications are IEC60904-9 2007, JIC C 8912, and ASTM E927-05. I-V curves were obtained by applying an external bias to the cell and measuring the generated photocurrent with a Keithley model 2400 digital source meter. The voltage step and delay time of photocurrent were 10 mV and 40 ms, respectively. Oriel IQE-200 was used to determine the monochromatic incident photon-to-electric current conversion efficiency. Under full computer control, light from a 150 W xenon arc lamp was focused through a monochromator in the 300-1800 nm wavelength range onto the photovoltaic cell under test. The monochromator was incremented through the visible spectrum to generate the IPCE (λ) as defined by IPCE (λ) = 12,400 (Jsc/ λ φ), where λ is the wavelength, Jsc is the short-circuit photocurrent density (mA cm⁻²), and φ is the incident radiative flux (mWcm⁻²). Photovoltaic performance was measured by using a metal mask with an aperture area of 0.09 cm².

High Resolution Scanning Electron Microscopy (HR-SEM). SIRIONHR SEM was performed with FEI (Field Emission Instruments), The Netherlands. The measurement conditions were 5 kV at a magnification of 39,000.

Kelvin probe force microscopy (KPFM). Various locations of the cleaved crosssections were measured by KPFM and consistent CPD profiles with same variations were obtained for each solar cell type. The measured CPD was constant over a day range. Topography and CPD were measured with a slow scan rate (0.1 Hz) and in the attractive force regime (force-distance curve) in order to avoid tip-sample crashes. Amplitude modulation KPFM was carried out with a commercial AFM (Dimension Edge, Bruker Inc.) inside a nitrogen glove box with less than 1 ppm H₂O at room temperature. The CPD was measured simultaneously with the topographic signal at an effective tip sample distance of 5 nm during scanning. The topographic height was obtained by maintaining the amplitude of the first cantilever resonance (f_{1st} 75 kHz) at a predefined amplitude set point of approximately 10 nm. The CPD was determined by compensating the ac component of the electrostatic force at angular frequency ω with an applied dc voltage (=|CPD|) in a feedback control loop. To separate topographic from CPD signal, increase the sensitivity, and minimize probesample convolution effects, the AC electrostatic force component was generated at the second resonance 26 , $f_{2nd} \approx 450\,$ kHz, of the cantilever by applying an ac voltage of about 500 mV. Highly conductive cantilevers with Pt/Ir coating (PPP EFM, Nanosensors) were used for KPFM.

- Nam, J. J. et al. o-Methoxy Substituents in Spiro-OMeTAD for Efficient Inorganic-Organic Hybrid Perovskite Solar Cells. J. Am. Chem. Soc. 136, 7837–7840 (2014).
- Dianyi, L. & Timothy, L. K. Perovskite solar cells with a planar heterojunction structure prepared using room-temperature solution processing techniques. *Nature photonics* 8, 133–138 (2014).
- Stranks, S. D. et al. Electron-Hole Diffusion Lengths Exceeding 1 Micrometer in an Organometal Trihalide Perovskite Absorber. Science 342, 341–344 (2013).
- Xing, G. C. et al. Long-Range Balanced Electron- and Hole-Transport Lengths in Organic-Inorganic CH₃NH₃PbI₃. Science 342, 344–347 (2013).
- Qi, C. et al. Planar Heterojunction Perovskite Solar Cells via Vapor-Assisted Solution Process. J. Am. Chem. Soc. 136, 622–625 (2014).
- Mingzhen, L., Michael, B. J. & Henry, J. S. Efficient planar heterojunction perovskite solar cells by vapour deposition. *Nature* 501, 395–399 (2013).
- Julian, B. et al. Sequential deposition as a route to high-performance perovskitesensitized solar cells. Nature 499, 316 (2013).
- Best Research cells efficiencies. http://www.nrel.gov/ncpv/images/efficiency_ chart.jpg, Date of access: 30/12/2014.



- Jacob, T. W. W. et al. Low-Temperature Processed Electron Collection Layers of Graphene/TiO₂Nanocomposites in Thin Film Perovskite Solar Cells. Nano Lett. 14, 724–730 (2014).
- 10. Bing, C. et al. High performance hybrid solar cells sensitized by organolead halide perovskites. Energy Environ Sci. 6, 1480 (2013).
- Eran, E., Saar, K., David, C. & Gary, H. High Open-Circuit Voltage Solar Cells Based on Organic-Inorganic Lead Bromide Perovskite. J. Phys. Chem. Lett. 4, 897–902 (2013).
- Eran, E. et al. Elucidating the charge carrier separation and working mechanism of CH3NH3PbI3_xClx perovskite solar cells. Nature comm, DOI: 10.1038/ ncomms4461 (2014).
- 13. Hui, S. K. *et al.* Mechanism of carrier accumulation in perovskite thin-absorber solar cells. *Nature communications* **4**, 2242 (2013).
- Peng, Q. et al. Yttrium-substituted nanocrystalline TiO₂photoanodes for perovskite based heterojunction solar cells. Nanoscale 6, 1508 (2014).
- Eran, E. et al. Why Lead Methylammonium Tri-Iodide Perovskite-Based Solar Cells Require a Mesoporous Electron Transporting Scaffold (but Not Necessarily a Hole Conductor). Nano Lett. 14, 1000–1004 (2014).
- Bergmann, W. Victor et al. Real-space observation of unbalanced charge distribution inside a perovskite-sensitized solar cell. Nature Communications 5, doi:10.1038/ncomms6001.
- 17. Nonnenmacher, M., O'Boyle, M. P. & Wickramasinghe, H. K. Kelvin probe force microscopy. *Appl. Phys. Lett.* **58**, 2921 (1991).
- 18. George, E. *et al.* The role of the cantilever in Kelvin probe force microscopy measurements. *Beilstein J. Nanotechnol* **2**, 252–260 (2011).
- Michael, M. L., Joël, T., Tsutomu, M., Takurou, N. M. & Henry, J. S. Efficient Hybrid Solar Cells Based on Meso-Superstructured Organometal Halide Perovskites. *Science* 338, 643–647 (2012).
- Sigalit, A., Shany, G., Bat, E. C. & Lioz, E. Depletion region effect of highly efficient hole conductor free CH3NH3PbI3 perovskite solar cells. *Phys. Chem. Chem. Phys.* 16, 10512 (2014).
- Seto, J. Electrical properties of polycrystalline silicon thin films. J. Appl. Phys. 46, 5247 (1975).
- Kamins, T. I. Hall mobility in chemically deposited polycrystalline silicon. J. Appl. Phys. 42, 4357–4365 (1971).
- Federico, B., Alison, B. W. & Aron, W. Structural and electronic properties of hybrid perovskites for high-efficiency thin-film photovoltaics from firstprinciples. APL Materials 1, 042111 (2013).

- Guerrero, A. et al. Electrical field profile and doping in planar lead halide perovskite solar cells. Appl. Phys. Lett. 105, 133902 (2014).
- Jeong, H., Jaehoon, C., Seung, J. K. & Nam, G. P. Synthesis, structure, and photovoltaic property of a nanocrystalline 2H perovskite-type novel sensitizer (CH₃CH₂NH₃)PbI₃. Nanoscale Research Letters 7, 353 (2012).
- Kikukawa, A., Hosaka, S. & Imura, R. Silicon pn junction imaging and characterizations using sensitivity enhanced Kelvin probe force microscopy. *Applied Physics Letters* 66, 3510 (1995).

Acknowledgments

We would like to thank the Israel Alternative Energy Foundation (I-SAEF) that financed this research, the Ministry of Industry Trade and Labor Office of the Chief Scientist Kamin project No.50303, and the Tashtiot project of the Office of the Chief Scientist.

Author contributions

A.D. prepared the cells and characterized them, analyzed the data and took part in the discussion. A.H. performed the KPFM measurements and took part in the discussion and the preparation of the paper. Y.R. is the supervisor of A.H. and he participated in the discussion. L.E. is A.D.'s supervisor; L.E. wrote the paper and planned its experiments. G.S. did the simulation of the band diagram and contribute in the discussion part. The paper was edited and approved by all authors.

Additional information

Competing financial interests: The authors declare no competing financial interests.

How to cite this article: Dymshits, A., Henning, A., Segev, G., Rosenwaks, Y. & Etgar, L. The electronic structure of metal oxide/organo metal halide perovskite junctions in perovskite based solar cells. *Sci. Rep.* 5, 8704; DOI:10.1038/srep08704 (2015).



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